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09/696,232 10/26/2000 Mitsuru Ishikawa 22852 7590 12/19/2002 FINNEGAN, HENDERSON, FARABOW, GARRETT &	07553.0017	5127
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EINNECAN HENDERSON EARAROW CARRETT &		
· · · · · · · · · · · · · · · · · · ·	EXAMINER	
DUNNER LLP 1300 I STREET, NW	OLSEN, ALLAN W	
WASHINGTON, DC 20006		
	ART UNIT	PAPER NUMBER
	1763	
DAT	E MAILED: 12/19/2002	· 4

Please find below and/or attached an Office communication concerning this application or proceeding.

•		Application No.	Applicant(s)		
Office Action Summary		09/696,232	ISHIKAWA ET AL		
		Examiner	Art Unit		
		Allan W. Olsen	1763		
Period for	Th MAILING DATE of this communication app Reply	ears on the cover sheet with the	correspondence address		
THE M - Extension after S - If the S - If NO - Failure - Any re	PRTENED STATUTORY PERIOD FOR REPLY IAILING DATE OF THIS COMMUNICATION. Sions of time may be available under the provisions of 37 CFR 1.13 (6) MONTHS from the mailing date of this communication. Deriod for reply specified above is less than thirty (30) days, a reply period for reply is specified above, the maximum statutory period we to reply within the set or extended period for reply will, by statute, ply received by the Office later than three months after the mailing I patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be within the statutory minimum of thirty (30) of will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDO	timely filed lays will be considered timely. om the mailing date of this communication. NED (35 U.S.C. § 133).		
1)⊠	Responsive to communication(s) filed on 26 C	October 2000 .			
2a) <u></u> □	This action is FINAL . 2b)⊠ Th	is action is non-final.			
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposition	on of Claims				
•	Claim(s) $1-12$ is/are pending in the application				
4a) Of the above claim(s) is/are withdrawn from consideration.					
5) Claim(s) is/are allowed.					
6)⊠ Claim(s) <u>1-12</u> is/are rejected.					
	/ 				
8) [] Application	Claim(s) are subject to restriction and/or on Papers	r election requirement.			
9)⊠ Т	he specification is objected to by the Examine	r.			
10)⊠ T	he drawing(s) filed on 26 October 2000 is/are:	a) accepted or b) objected t	o by the Examiner.		
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).					
11) The proposed drawing correction filed on is: a) ☐ approved b) ☐ disapproved by the Examiner.					
If approved, corrected drawings are required in reply to this Office action.					
12)☐ The oath or declaration is objected to by the Examiner.					
Priority under 35 U.S.C. §§ 119 and 120					
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).					
a)[2	All b) Some * c) None of:				
	1. Certified copies of the priority documents have been received.				
	2. Certified copies of the priority documents have been received in Application No				
 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 					
14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).					
a)	☐ The translation of the foreign language procknowledgment is made of a claim for domesti	ovisional application has been r	eceived.		
Attachment		, ,			
1) Notice	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice of Inform	ary (PTO-413) Paper No(s) al Patent Application (PTO-152)		
LS Patent and Tra	demail Office				



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DETAILED ACTION

Drawings

The drawings are objected to because figure 1 depicts gas supply 142 as being a source of H₂, however, the specification does not disclose the use of inert gases Ar, He and Kr rather than H₂. A proposed drawing correction or corrected drawings are required in reply to the Office action to avoid abandonment of the application. The objection to the drawings will not be held in abeyance.

Specification

The disclosure is objected to because of the following informalities: on page 6, gas supply 136 is said to be a source of CF4, gas supply 142 is said to be a source of N2 and gas supply 148 is said to be a source of Ar. These characterizations do not correspond with the depiction in figure 1.

Additionally, the examiner notes that the specifiacation makes reference to claim numbers when discussing cvariuos cliam limitations. This requires particular attention should the application issue as a patent because upon issue of the patent, claim numbers are subject to change.

Appropriate correction is required.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

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Recent Statutory Changes to 35 U.S.C. § 102(e)

On November 2, 2002, President Bush signed the 21st Century Department of Justice Appropriations Authorization Act (H.R. 2215) (Pub. L. 107-273, 116 Stat. 1758 (2002)), which further amended 35 U.S.C. § 102(e), as revised by the American Inventors Protection Act of 1999 (AIPA) (Pub. L. 106-113, 113 Stat. 1501 (1999)). The revised provisions in 35 U.S.C. § 102(e) are completely retroactive and effective immediately for all applications being examined or patents being reexamined. Until all of the Office's automated systems are updated to reflect the revised statute, citation to the revised statute in Office actions is provided by this attachment. This attachment also substitutes for any citation of the text of 35 U.S.C. § 102(e), if made, in the attached Office action.

The following is a quotation of the appropriate paragraph of 35 U.S.C. § 102 in view of the AIPA and H.R. 2215 that forms the basis for the rejections under this section made in the attached Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

35 U.S.C. § 102(e), as revised by the AIPA and H.R. 2215, applies to all qualifying references, except when the reference is a U.S. patent resulting directly or indirectly from an international application filed before November 29, 2000. For such patents, the prior art date is determined under 35 U.S.C. § 102(e) as it existed prior to the amendment by the AIPA (pre-AIPA 35 U.S.C. § 102(e)).

The following is a quotation of the appropriate paragraph of 35 U.S.C. § 102 prior to the amendment by the AIPA that forms the basis for the rejections under this section made in the attached Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in a patent granted on an application for patent by another filed in the United States before the invention thereof by the applicant for patent, or on an international application by another who has fulfilled the requirements of paragraphs (1), (2), and (4) of section 371(c) of this title before the invention thereof by the applicant for patent.

For more information on revised 35 U.S.C. § 102(e) visit the USPTO website at www.uspto.gov or call the Office of Patent Legal Administration at (703) 305-1622.



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Claims 7-10 and 12 are rejected under 35 U.S.C. 102(e) as being anticipated by U.S. Patent 6,284,149 issued to Li et al. (hereinafter, Li).

Li teaches using a mixture of C4F8 and N2, with a 3:45 flow ratio, to etch a layer of low k dielectric material such as BCB that overlies a nitride layer. See column 11.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-6 and 11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Li as applied to claims 7-10 and 11 above, and further in view of US Patent 6,325,861 issued to Stinnett.

Li teaches etching a layer of low k dielectric material such as BCB that overlies both an oxide layer and a nitride layer. See figure 5 and column 6, line 56 - column 7, line 67.

Li does not teach using CF4 as the fluorocarbon etchant or including Ar as a component of the etching gas mixture.

Stinnett teaches etching dielectrics such as oxides, nitirides and BCB with an etchant mixture such as CF4, N2 and Ar.

It would have been obvious to one skilled in the art to add Ar to the etchant of Li because Stinnett teaches that Ar enhances the sputtering aspect of the etching process Application/Control Number: 09/696,232

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(column 5, lines 6-8). It would have been obvious to use CF4 because Stinnett teaches that CF4 functions equivalently to the C4F8 of Li. Additionally, Li teaches that Dow Chemical, the manufacturer of BCB, recommends etching with CF4 and Ar (column 4, lines 40-44).

Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Allan Olsen whose telephone number is 703-306-9075. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Greg Mills, can be reached on 703-308-1633.

The general fax numbers for TC1700 are 703-872-9310 (non-after finals) and 703-872-9311(after-final).

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the Group receptionist whose telephone number is (703) 308-0661.

Allan Olsen, Ph.D. December 16, 2002